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Nota di contenuto	Advanced Dielectric, Piezoelectric and Ferroelectric Thin Films; Contents; Preface; Chemical Solution Deposition of CaCu ₃ Ti ₄ O ₁₂ Thin Films; The Temporal Effects in DC-Biased PbNb(Zr,Sn,Ti)O ₃ ; High Energy Density PLZT Thin Film Capacitors; Reliability Studies on Sputter Deposited Barium Strontium Titanate Thin Film Capacitors; Raman Study of Effects of Excess Bi Content in Metalorganic Derived Bi ₄ Ti ₃ O ₁₂ Films; High Dielectric Tunability Ferroelectric (Pb,Sr)TiO ₃ Thin Films for Room Temperature Tunable Microwave Devices; Fabrication of Self-Assembled Nanostructures of Microwave Dielectrics Epitaxial Phase Selection in the Rare Earth Manganite System Multi-Ferroic BiFeO ₃ Films Prepared by Liquid Phase Epitaxy and Sol-Gel Methods; Effect of Argon Addition During ECR Mode Nucleation of Diamond Films Grown by MPCVD; Author Index; Keyword Index
Sommario/riassunto	Advances in synthesis and characterization of dielectric, piezoelectric

and ferroelectric thin films are included in this volume. Dielectric, piezoelectric and ferroelectric thin films have a tremendous impact on a variety of commercial and military systems including tunable microwave devices, memories, MEMS devices, actuators and sensors. Recent work on piezoelectric characterization, AFE to FE dielectric phase transformation dielectrics, solution and vapor deposited thin films, and materials integration are among the topics included. Novel approaches to nanostructuring, characterization of m
